



**THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant : Mao-Yi CHANG et al. Confirmation No: 1409  
Appl. No. : 10/635,489  
Filed : August 7, 2003  
Title : METHOD FOR TRANSFORMING AN AMORPHOUS  
SILICON LAYER INTO A POLYSILICON LAYER  
  
TC/A.U. : 2818  
Examiner : D. Vu  
  
Docket No.: : CHAN3214/REF  
Customer No: : 23364

**AMENDMENT**

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of September 12, 2005, in connection with the above-identified application. This response is timely filed.

Please amend the application as follows:

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.